## DIRECT WATER SPLITTING BY NEW OXIDE SEMICONDUCTOR PHOTOCATALYSTS UNDER VISIBLE LIGHT IRRADIATION

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Hydrogen production by direct splitting of water using photocatalysts under solar light is one of the most attractive research subjects in terms of a clean energy supply in future. Therefore, a number of researches on photocatalytic splitting of water have been conducted so far. As a result, several oxide semiconductor such  $Na_2CO_3$ -Pt/TiO<sub>2</sub>,<sup>1)</sup> photocatalysts, as  $NiO_x/K_4Nb_6O_{17}^{,2}$   $NiO_x/Ta_2O_5^{,3)}$ , and  $NiO_x/NaTaO_3^{,4)}$ , which were able to split water under UV light irradiation, were reported. However, photocatalysts, which can utilize visible light for stoichiometric splitting of water, have not been developed so far. We have been investigating such photocatalytic systems using two different new approaches. The one is to design and synthesize narrow band gap oxide semiconductor photocatalysts which are able to split water under visible light irradiation. The other is to design the two-step water splitting system which is composed of the combination of two different oxide semiconductor photocatalysts for  $H_2$  and  $O_2$ production, respectively, and a shuttle redox mediator between two photocatalysts. This system mimics the Zscheme mechanism in natural photosynthetic process. These new approaches are introduced and discussed.

We have synthesized various kinds of new mixed oxide semiconductor materials which could absorb visible light. The first group is  $Bi_2MNbO_7$  (M= Al<sup>3+</sup>, Ga<sup>3+</sup>,  $In^{3+}$ ,  $Y^{3+}$ , Rare Earth<sup>3+</sup>) <sup>5)</sup> of A<sub>2</sub>B<sub>2</sub>O<sub>7</sub> pyrochlore structure. The second group is BiMO<sub>4</sub> (M=Nb<sup>5+</sup>, Ta<sup>5+</sup>)<sup>6)</sup> of stibotantalite structure and the third group is InMO4  $(M=Nb^{5+}, Ta^{5+})^{7)}$  of wolframite structure. These materials crystallize in the different structures, however, they contain the same octahedral TaO<sub>6</sub> and/or NbO<sub>6</sub> in the structures. The band structure of these materials is estimated that the conduction band is composed of Ta/Nb d-level mainly and the valence band is composed of O 2plevel mainly. The band gaps of these materials determined by UV-visible reflectance spectra were between 2.7 and 2.4 eV. Among these materials, NiO<sub>x</sub> (surface oxidized Ni) or RuO<sub>2</sub> promoted InTaO<sub>4</sub> and InNbO<sub>4</sub> photocatalysts, such as NiO<sub>x</sub>/InTaO<sub>4</sub>, RuO<sub>2</sub>/InTaO<sub>4</sub> and NiO<sub>x</sub>/InNbO<sub>4</sub>, showed photocatalytic activities for pure water splitting under visible light irradiation ( $\lambda > 420$  nm, 300W Xelamp). However, the activities were very low.

In order to improve water splitting activity, transition metal doped  $InTaO_4$  and  $InNbO_4$  were synthesized.<sup>8)</sup> Among these doped materials, Ni-doped  $InTaO_4$  and Ni-doped  $InNbO_4$  photocatalysts such as  $NiO_x/In_{0.9}Ni_{0.1}TaO_4$ ,  $RuO_2/$ In<sub>0.9</sub>Ni<sub>0.1</sub>TaO<sub>4</sub>, NiO<sub>x</sub>/  $In_{0.9}Ni_{0.1}TaO_4$  and  $RuO_2/\ In_{0.9}Ni_{0.1}TaO_4$  showed the highest activities. The rate of H<sub>2</sub> and O<sub>2</sub> evolution were 16.6 and 8.3  $\mu$  mol/h, respectively, and the quantum efficiency at 402 nm was 0.66% in the case of 1wt% NiO<sub>x</sub>/  $In_{0.9}Ni_{0.1}TaO_4$  photocatalyst.<sup>9)</sup> The absorption band due to Ni-doping was observed at 420-520nm in addition to that of  $In_{0.9}Ni_{0.1}TaO_4$ . This is one of reasons of activity increase. The stability of this photocatalyst and reproducibility of photocatalytic water splitting reaction were fairly good. TEM photographs of  $In_{0.9}Ni_{0.1}TaO_4$  photocatalyst showed the particles size were 300 to 500 nm and  $NiO_x$  particles on  $In_{0.9}Ni_{0.1}TaO_4$ , were 15 to 30 nm. A clear formation of stepped- structure was also observed in  $In_{0.9}Ni_{0.1}TaO_4$  particles and TEM-EDAX analysis showed  $In_{0.9}Ni_{0.1}TaO_4$  has a homogeneous atomic distribution.<sup>10</sup>

The first principle calculations were conducted to determine of the band structure of  $In_{0.9}Ni_{0.1}TaO_4$  using of  $In_{14}Ni_2Ta_{16}O_{64}$  model. The electrons from the Ni-3d<sup>8</sup> dopant seem to be somewhat delocalized, thus contributing to the formation of the new band with the O-2p electrons. Based on a comparison with the light absorption and photocatalytic activity, we think the  $e_g$  state of the Ni-3d<sup>8</sup> plays a significant role in the photocatalytic splitting of pure water under visible light irradiation.

In natural photosynthesis, carbohydrate and O<sub>2</sub> are formed from CO<sub>2</sub> and water under solar light using socalled Z-scheme reaction composed of two photoexcitation centers, PSI and PSII, and many redox mediators. In order to develop the photocatalytic water splitting into H<sub>2</sub> and O<sub>2</sub> stoiciometrically under visible light irradiation, the mimicking system of the Z-scheme mechanism using reversible redox mediators (Ox/Red) was investigated. To look for the stable shuttle redox mediator and its appropriate reaction condition is very important. We found IO<sub>3</sub><sup>-</sup>/I<sup>-</sup> redox system could work for water splitting using the mixture of Pt/TiO<sub>2</sub>(anatase) and TiO<sub>2</sub>(rutile) photocatalysts as PSI[H<sub>2</sub>] and PSII[O<sub>2</sub>], respectively. The H<sub>2</sub> evolution took place over Pt/TiO<sub>2</sub> (anatase) with the oxidation of I<sup>-</sup> to IO<sub>3</sub><sup>-</sup>, and O<sub>2</sub> evolution took place over  $TiO_2$  (rutile) with the reduction of  $IO_3^-$  to  $\Gamma$  in the one reactor under UV light irradiation.<sup>11)</sup>

Various kinds of visible light responding oxide semiconductor photocatalysts, such as Fe2O3, Bi2WO6, In<sub>2</sub>O<sub>3</sub>(ZnO)<sub>9</sub>, CrTaO<sub>4</sub>, InTaO<sub>4</sub>, SrTiO<sub>3</sub> and so on, were screened for H<sub>2</sub> evolution from water including I<sup>-</sup> ion as a reversible electron donor. On the other hand, O<sub>2</sub> evolution from water including IO<sub>3</sub><sup>-</sup> as a reversible electron acceptor was also tested using various kinds of oxide semiconductor photocatalysts such as WO<sub>3</sub>, In<sub>2</sub>O<sub>3</sub>, Bi<sub>2</sub>O<sub>3</sub>, BiVO<sub>4</sub>, CuWO<sub>4</sub>, NiWO<sub>4</sub> and so on. Finally, we found both  $H_2$  and  $O_2$  evolution with a stoichiometric ratio of  $H_2/O_2=2/1$  occurred stably for more than 250 h under visible light irradiation using a mixture of Pt/WO3 photocatalysts for O2 evolution and Pt/StTiO3(Cr, Tadoped) photocatalyst for H<sub>2</sub> evolution in NaI aqueous solution. We established a new visible light water splitting system with a two-step photo-excitation mechanism using a pair of  $I/IO_3^-$  shuttle redox mediator. The quantum efficiency at 420 nm was about 0.1%.<sup>12,1</sup>

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